

**Search Notes**

Application/Control No.

10/712,923

Examiner

Toan Ton

Applicant(s)/Patent under  
Reexamination

IWASA ET AL.

Art Unit

2871

**SEARCHED**

Class	Subclass	Date	Examiner
349	137	7/29/2005	TTON
	44,38		
	110		
	113		
	<del>110</del>		
313	503		

**INTERFERENCE SEARCHED**

Class	Subclass	Date	Examiner
349	44,110,38	7/29/2005	TTON
	113,137		
313	503		

**SEARCH NOTES  
(INCLUDING SEARCH STRATEGY)**

	DATE	EXMR
EAST liquid crystal reflect\$ antireflect\$/anti reflect\$ black mask/matrix light shield\$/block\$ silicon metal\$5 gap\$	7/29/2005	TTON